Docket No.

202450US0

IN RE APPLICATION OF: Atsushi SHIOTA, et al.

SERIAL NO: 09 770,289

FILED:

FOR:

PROCESS FOR PRODUCING SILICA-BASED FILM, SILICA-BASED FILM, INSULATING FILM, AND January 29, 2001

SEMICONDUCTOR DEVICE

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

Transmitted herewith is an Amendment w Attachment (10 pp.) in the above-identified application.

☐ No additional fee is required

☐ Small entity status of this application under 37 C.F.R. §1.9 and §1.27 is claimed.

APROCEIVED TO 1700 Request for Extension of Time Under 37 C.F.R. §1.136 (one month) Additional documents filed herewith: Declaration Under 37 C.F.R. §1.132 (3 pp., executed)

The Fee has been calculated as shown below:

CLAIMS	CLAIMS REMAINING		HIGHEST NUMBER PREVIOUSLY PAID	NO. EXTRA CLAIMS	RATE			CALCULATIONS
			20	0	X	\$18	=	\$0.00
ΓΟΤΑL	16	MINUS	20	0	$\frac{1}{x}$	\$84	=	\$0.00
INDEPENDENT	1	MINUS	3	GL AIMS	+	\$280	=	\$0.00
		☐ MULTIPLE DEPENDENT CLAIMS  TOTAL OF ABOVE CA  Reduction by 50% for filing by Small Entity					ONS	\$0.00 \$0.0
								\$0.0
		☐ Recordation of Assignment			+		= TAL	\$0.0

■ A check in the amount of \$110.00 is attached.

- Please charge any additional Fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.
- If these papers are not considered timely filed by the Patent and Trademark Office, then a petition is hereby made under 37 C.F.R. §1.136, and any additional fees required under 37 C.F.R. §1.136 for any necessary extension of time may be charged to Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C wer part Unlack

Norman F. Oblon

24,618 Registration No.

OSMMN = 1